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Resonant Network Antennas for Radio-Frequency Plasma Sources

Theory, technology and applications

Philippe Guittienne Alan Howling Ivo Furno

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Preface

Radio frequency plasmas provide the underlying technology for many of today's critical semiconductor industries. The demand for larger and more uniform plasma sources is reaching the limits of conventional capacitive and inductive RF plasma reactors, due to standing wave effects and the asymptotic impedance of large-area reactors. The inherent properties of resonant network antennas can overcome these limitations because of their spatially distributed internal resonances and real input impedance.

This book aims to show that resonant network antennas are versatile, alternative sources for inductively coupled and wave-driven plasma. The theory has developed alongside the technology (see also https://www.helyssen.com) to the extent that it is timely to document the progress in an accessible way, to aid antenna design for future RF plasma applications.

To maximize the usefulness of this book for the physicist, engineer, and student, we have taken care to provide all the necessary details for the reader. In particular:

- Equations are derived in full with all intermediate steps.
- Unfamiliar techniques, such as partial inductance calculations, the complex image method, and partial image theory are developed step-by-step from elementary principles by means of explanatory figures.
- The most useful and recurring antenna calculations are provided using a link to programs which reproduce the tensor solutions and many of the book's figures in appendix K.
- Basic concepts in plasma physics are explained, occasionally using a novel approach.

We assume an undergraduate science level familiar with complex numbers, complex impedance, and Maxwell's equations. The chapters and appendixes are cross-referenced throughout the book, but for the most part, the chapters can be read independently of each other. MKS SI units are used throughout. We use 'antennas' for the plural of 'antenna', with apologies to Latin scholars.

The readers will be grateful to Alex Howling, our illustrator, for bringing a touch of comic relief to each chapter.

Dr Philippe Guittienne Dr Alan Howling Professor Ivo Furno Lausanne, Switzerland, 26 October 2023

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Individual projects are acknowledged in full in the publications referenced throughout the book.

Author biographies

Philippe Guittienne



Dr Philippe Guittienne is currently a physicist at the Swiss Plasma Center (SPC) in the Basic Plasma Physics and Applications group under Professor Ivo Furno, and founder of the Helyssen Sàrl company in 2003. Following an engineering degree in physics (1997) and a doctorate (2002) in condensed matter physics at the EPFL on magnetization reversal in ferromagnetic nanostructures, he completely changed his field of interest to birdcages for helicon sources, inspired by the PhD on MRI of his future wife, Jacqueline.

On the basis of this intuition, he founded the Helyssen Sàrl start-up in 2003, and started a collaboration with Dr Christoph Hollenstein's group at SPC for the development of resonant antennas as plasma sources. This topic turned out to be a fruitful field of research, and during the years it became a central part of the Industrial Plasma Group (now included in Basic Plasma Physics and Applications), and is, indeed, the subject of this book.

Alan Arthur Howling



Dr Alan Arthur Howling is an Adjoint Scientifique/Senior Scientific Collaborator, co-founder of the group for industrial plasmas in 1989 with Dr Christoph Hollenstein. He is currently a researcher and lecturer in the Basic Plasma Physics and Applications group under Professor Ivo Furno at the Swiss Plasma Center, EPFL, Lausanne, Switzerland. A Gordon Warter Open Scholarship in 1978 to Pembroke College, Oxford University, led to a physics (Natural Sciences) degree in 1981, followed by an MSc and Gordon Francis

prize (1982) in the Science and Applications of Electric Plasmas at Wolfson College, Oxford University, and then a doctorate titled 'Fluctuations in the edge plasma of the TOSCA tokamak' (1985) at both Oxford and UKAEA Culham Laboratory, as it was then called. A postdoc on the TCA tokamak in the Centre de Recherches en Physique des Plasmas (CRPP), EPFL Lausanne, Switzerland from 1986 to 1989 was the springboard to RF industrial plasmas in 1989. Applied research topics included negative ion polymerization (silanions) and particle formation in silane RF plasmas; design of large-area RF capacitive plasma reactors for solar cells and flat panel displays, including showerhead uniformity, discharge equilibration, plasmoids, and electromagnetic analysis of symmetric and anti-symmetric modes; RF plasma deposition of amorphous and micro-crystalline silicon; RF plasma diagnostics and glass substrate charging; design of resonant ladder networks for RF plasmas, introducing partial inductance and complex image methods; high voltage design of satellite slip-rings; bio-plasma with Alexandra Waskow and the effect of humidity on dielectric barrier discharges; finally concentrating on writing this swan-song book before retirement on 26 October 2023.

Ivo Furno



Professor Ivo Furno is currently Adjunct Professor at the EPFL and leader of the Basic Plasma Physics and Applications (BPPA) group of the Swiss Plasma Center. He graduated in Nuclear Engineering from the Politecnico di Torino, Italy, in 1995 and then received his PhD from the EPFL with a thesis on 'Fast transient transport phenomena measured by soft x-ray emission in TCV tokamak plasmas'. He continued with a postdoc at the Los Alamos National Laboratory, where he studied magnetic reconnection on

the Reconnection Scaling Experiment (RSX), before re-joining the EPFL in 2006. His research is marked by the use of human-scale, dedicated plasma devices to investigate the fundamental physics of plasmas under conditions ranging from fusion plasmas to plasmas of relevance for solar physics and to non-equilibrium cold plasmas for industrial and biological applications. For his work on turbulence in magnetized plasmas, he was awarded the Fellowship of the American Physics Society. On the TCV tokamak, he contributed to the development of the first experiments on the so-called snowflake divertor, and, recently, he led the TCV team that obtained the first experimental demonstration of electron cyclotron microwave beam broadening by plasma turbulence. Since he took over the responsibility of the BPPA group, he has obtained numerous grants to develop industrial applications in collaboration with national academic institutions as well as with industrial partners. He developed the Resonant Antenna Ion Device (RAID) and launched its scientific program to study the physics of helicon waves and negative ion volume generation in helicon plasmas. As part of the new SPC activities beyond fusion, he started collaborating with CERN in the field of wakefield acceleration for the nextgeneration particle accelerator. The SPC is today an active member of the AWAKE Consortium. A new laboratory for societal, e.g. biological, applications of plasmas, such as plasma agriculture and plasma sterilization, was launched by Furno to expand the SPC infrastructure into atmospheric pressure plasmas for fundamental life science projects. It was Furno who originally proposed writing this book, titled Resonant Network Antennas for Radio-Frequency Plasma Sources.



The authors in front of the RAID device: Philippe Guittienne, Alan Howling, and Ivo Furno.

Glossary

Greek terms

| α | attenuation constant per section |
|---------------------------|---|
| α | a Fourier coefficient |
| ß | phase change per section (rad) |
| ß | a Fourier coefficient |
| β_{1} | wavenumber for H. TG modes (m^{-1}) |
| ν γ | pronagation constant |
| Λf | FWHM bandwidth (Hz) |
| $\frac{-}{\delta}$ | Dirac delta function |
| δω | a small difference in angular frequency from the resonance frequency (rad s^{-1}) |
| $\Delta \omega$ | the FWHM half-power bandwidth in angular frequency (rad s^{-1}) |
| <i>E</i> 0 | permittivity of free space (F m^{-1}) |
| \mathcal{E}_n | relative permittivity of unmagnetized plasma (-) |
| $\bar{\bar{e}}_{n}^{\nu}$ | tensor relative permittivity of magnetized plasma (-) |
| ζ_m | a Fourier coefficient |
| η | power transfer efficiency |
| θ | angle of propagation with respect to the magnetic field |
| λ | wavelength (m) |
| μ_0 | permeability of free space (H m^{-1}) |
| ν | effective collision frequency (s ⁻¹) |
| ν_m | electron–neutral collision frequency (s^{-1}) |
| ξ_m | a Fourier coefficient |
| ρ | free charge density (C m^{-3}) |
| $ ho_{ m dc}$ | DC electrical resistivity (Ω m) |
| $ ho_p$ | plasma complex electrical resistivity (Ω m) |
| $\sigma_{ m dc}$ | DC electrical conductivity (S m ⁻¹) |
| $\sigma_{ m en}$ | electron–neutral collision cross-section (m ²) |
| σ_p | complex electrical conductivity of unmagnetized plasma (S m^{-1}) |
| $\bar{\sigma}_p$ | tensor electrical conductivity of magnetized plasma (S m^{-1}) |
| τ | RF period $=2\pi/\omega$ (s) |
| Φ | total magnetic flux linkage (Wb) |
| φ | azimuthal angle in cylindrical coordinates (r, ϕ, z) |
| ω | angular (RF) frequency (rad s) |
| ω | $(\omega + j\nu)$ |
| ω_0 | resonance angular frequency for a real (loss) circuit (rad s ^{-1}) |
| w_0 | angular frequency of the mth normal mode (rad s^{-1}) |
| w _m | ion evolution angular frequency (rad s^{-1}) |
| w _{ci} | electron cyclotron angular frequency (rad s ⁻¹) |
| wce | cicción cyclotion angular requency (rad s) |
| Symbo | ols, abbreviations, and subscripts |

| ī | $N \times N$ identity matrix |
|--------|---|
| 1D, 2D | one-dimensional, two-dimensional |
| Α | vector magnetic potential (Wb m ⁻¹) |
| Α | vector column of upper-node voltages (V) |
| acw | anti-clockwise |

| ALD | atomic layer deposition |
|---------------------|--|
| A_n | voltage phasor at the <i>n</i> th node of the upper stringer (V) |
| B | (wavefield) magnetic flux density vector (T) |
| В | vector column of lower-node voltages (V) |
| В | magnetic flux density magnitude (T) |
| \mathbf{B}_0, B_0 | externally imposed constant, uniform magnetic flux density (T) |
| $B_{\rm m}$ | voltage phasor at the <i>n</i> th node of the lower stringer (V) |
| C | canacitance (F) |
| Ĉ | capacitance matrix per unit length (F m^{-1}) |
| CCD | charge-coupled device (CCD camera) |
| CCP | canacitively coupled alarma |
| | contour |
| c c | speed of light in vacuum |
| c a | (subscript) collisional |
| l avv | |
| CW | ciockwise |
| | continuous wave, steady state |
| a J | reactor neight between a top-plate and a baseplate |
| a_s | source neight above an interface |
| us D | elemental length vector along a contour |
| | connection configuration term |
| DC | direct current, time-constant value |
| DLC | diamond-like carbon $(1, 1)$ $(2, 710)$ |
| e | the base of natural logarithms, Euler's number (2./18) |
| e | electron (subscript) |
| | (waveneid) electric field intensity vector (V m ⁻¹) |
| <i>E</i> -mode | coupling via the E field; see CCP |
| | electromagnetic |
| <i>EM</i> -mode | coupling via <i>EM</i> fields; see EMCP |
| EMC | electromagnetic compatibility |
| EMCP | electromagnetically coupled plasma |
| eq | |
| FIIK | Fourier transform infrared |
| FWHM | full width at half maximum |
| f_{c} | current feed point (subscript) |
| f_{c} | frequency (Hz) |
| $J_{\rm RF}$ | RF frequency (Hz) |
| $J_{\rm pe}$ | electron plasma frequency (Hz) |
| $f_{\rm pi}$ | ion plasma frequency (Hz) |
| f_{R} | plasma frequency (Hz) |
| G | conductance per unit length (S m ⁻¹) |
| g | ground point (subscript) |
| h | height of an antenna above a baseplate |
| H | magnetic field strength vector (A m ⁻¹) |
| Н | helicon |
| <i>H</i> -mode | coupling via the H field; see ICP |
| I | leg current column vector (A) |
| I | current (A) |
| ICP | inductively coupled plasma |
| Im | imaginary part |
| ISM | International Scientific and Medical standard |

| - | |
|--|---|
| I_n | current phasor in the <i>n</i> th leg (A) |
| i _{line} | current phasor of current along the line (A) |
| $i_{\rm rf}$ | current phasor of injected RF current (A) |
| i_0 | amplitude of the first harmonic of shell current density (A m^{-1}) |
| i. | shell current density (A m^{-1}) |
| I | first kind of Bessel function of order m (see Y) |
| J I | current in the <i>n</i> th upper stringer section (Λ) |
| J_n | $\sqrt{\frac{1}{1}}$ |
| J | $\sqrt{-1}$ |
| Λ_n | current in the <i>n</i> th lower stringer section (A) (-1) |
| K | wavenumber vector (m ⁻¹) |
| k | magnitude of the wavenumber vector \mathbf{k} (m ⁻¹) |
| k_0 | wavenumber in vacuum; $k_0 = \omega/c \text{ (m}^{-1})$ |
| k_d | wavenumber in a dielectric (m^{-1}) |
| k_z | axial wavenumber, along z (m ⁻¹) |
| $k_{\rm I}$ | perpendicular wavenumber, perpendicular to $z \text{ (m}^{-1})$ |
| k _R | Boltzmann's constant $(1.38 \cdot 10^{-23} \text{ J K}^{-1})$ |
| LHS | left-hand side |
| L | self partial inductance (H) |
| $\overline{\hat{L}}$ | self partial inductance per unit length (H m ^{-1}) |
| \overline{I}_{1} | self partial inductance of a leg (H) |
| L_{leg} | self partial inductance of a stringer segment (H) |
| <i>L</i> _{str} <i>I</i> loop | loop self inductance of a wire loop, coil, or solenoid (H) |
| \hat{I}^{loop} | loop self inductance of a wire loop, coll, of solehold (II) |
| L I loop | soptribution to loop self inductores of the <i>i</i> th wire segment (H) |
| L_i | contribution to loop sen inductance of the <i>i</i> th whe segment (H) |
| 1 | length of a wire, or an antenna leg |
| leg | leg (or rung) across the ladder width; or a birdcage leg |
| MRI | magnetic resonance imaging |
| M | mutual partial inductance matrix per unit length (H m^{-1}) |
| M_{ij} | mutual partial inductance between wire filaments i and j (H) |
| m | mode number |
| т | azimuthal periodicity |
| m_e | electron mass (kg) |
| mes | measured, or measurement |
| NMR | nuclear magnetic resonance |
| Ν | total number of legs |
| Ν | refractive index |
| nc | (subscript) non-collisional, or collisionless |
| n_{-0} | time-constant electron number density (m^{-3}) |
| OTR | oxygen transmission rate (c c m^{-2} atm $^{-1}$ day ⁻¹) |
| PEC | perfect electric conductor |
| PECVD | plasma enhanced chemical vanour denosition |
| | BE input power (W) |
| $r_{\rm rf}$ | Kr input power (w) Menuell's notential coefficient matrix (A) |
| <i>P</i> | maxwell's potential coefficient matrix (v) |
| p.u.1. | per unit length (signified by a nat above the symbol) |
| q | magnitude of the electron charge; $q = +1.602 \cdot 10^{-10} \text{ C}$ |
| <u>V</u> | quality factor |
| KAID | Resonant Antenna Ion Device |
| Re | real part |
| res | resonance (subscript or superscript) |
| RF, rf | radio frequency |

| RHS | right-hand side |
|---------------------|---|
| R | resistance, real impedance (Ω) |
| Ŕ | resistance per unit length (Ω/m) |
| <i>R</i> , <i>r</i> | radius (m) |
| r | resistance (Ω) |
| S | Poynting's vector $\mathbf{E} \times \mathbf{H}$ (W m ⁻²) |
| S | area (m ²) |
| S_n^J | source current at the <i>n</i> th node of the upper stringer (A) |
| S_n^K | source current at the <i>n</i> th node of the lower stringer (A) |
| sccm | a gas mass flow rate in standard cubic centimetres per second |
| Scrn | algebraic terms depending on currents induced in a PEC screen |
| SiO_x | silicon oxide with intermediate stoichiometry; $x = 1-2$ |
| SLM | a gas mass flow rate in standard litres per second |
| str | stringer, along the length of a ladder |
| Т | absolute temperature (K) |
| T_e | electron temperature |
| Т | Trivelpiece–Gould mode (subscript) |
| T–G | Trivelpiece–Gould mode |
| TM | transverse magnetic |
| \bar{U}_L | lower shift matrix |
| $V_{\rm pp}$ | peak-to-peak voltage (V) |
| $V_{\rm rf}$ | phasor of the applied RF voltage (V) |
| υ | velocity (m s ⁻¹) |
| υ | phase velocity (m s^{-1}) |
| <i>W</i> -mode | coupling via helicon wave fields |
| X | $N \times N$ matrix for parameters X_{nm} |
| X | column vector array for parameters X_n |
| X | reactive (imaginary) impedance (Ω) |
| Ŷ | unit vector along the x-axis |
| Y | complex admittance (S) |
| Y _{eq} | complex equivalent circuit admittance at resonance (S) |
| y | unit vector along the y-axis |
| Y_m | second kind of Bessel function, of order <i>m</i> (see J_m) |
| Z | complex impedance (Ω) |
| $Z_{\rm str}$ | stringer complex impedance (Ω) |
| Z_{leg} | leg complex impedance (12) |
| Z_{c} | characteristic impedance of a transmission line (Ω) |
| Z_{in} | equivalent circuit complex input impedance (12) |
| \sum_{in} | complex input impedance at resonance (12) |
| Z | unit vector along the z-axis |